

Czochralski방법에 의한 β -BaB₂O₄단결정 성장

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β -BaB₂O₄는 고출력 가시광선 및 적외선을 발진시키는데 유용한, 비선형 특성을 가진 물질이다. α - β 상전이 온도가 녹는점보다 180°C 낮기 때문에 보통 flux법으로 단결정을 성장시킨다. 수년전 Itoh등¹⁾은 β -BaB₂O₄단결정을 congruent조성의 용액으로부터 Czochralski법으로 metastable한 상태에서 직접 성장시켰다. 그렇지만 그 공정은 잘 이해되지 않고 있으며 재현하기가 매우 어렵다.

저자들은 β -BaB₂O₄단결정을 용액표면온도 1035°-1085°C, pulling rate 3mm/h, 10-30 rpm의 범위에서 성장시켰으며 용액표면의 온도구배는 β -상으로 성장시키는데 매우 중요한 인자로 여겨진다. Seed로는 직경 1-2mm의 c축방향 β -BaB₂O₄단결정 봉이 사용되어 성장방향을 조절하고 열응력을 최소화시켰다. 성장된 β -상의 단결정들은 6-fold모양을 하며 표면에 작은 비늘같은 것들이 불어있고 중심부에 core가 있는 것을 알았다. Flux법으로 성장시킨 β -BaB₂O₄단결정을 사용한 seeds는 단결정 성장 및 냉각 중에 cracks이 자주 발생하였으며, boule의 cracks은 afterheater를 사용할 경우 다소 줄일 수 있었다. 성장된 단결정의 광학특성이 측정되었다.

1) K. Itoh, F. Marumo and Y. Kuwano, " β -Barium Borate Single Crystal Grown by a Direct Czochralski Method," J. Crystal Growth 106, 728 (1990).

Growth of Single Crystal β -BaB₂O₄ by the Direct Czochralski Method

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Objectives

- β -BaB₂O₄(BBO) crystals for high-power visible and UV generation
- Fast, high-yield growth process
- Improved optical quality: high crystal uniformity and elimination of scattering defects
- Low manufacturing cost process

Approach

- Use metastable (derect) melt growth for 100 times faster growth rates
- Determine thermal parameters for consistent growth of β -phase
- Eliminate the use of solvent to prevent flux inclusions and reduce optical scatter
- Develop reproducible seeding technique to maximize yield

Properties of BaB₂O₄

Space group

α (high temperature) R̄3c (trigonal
 β (low temperature) R3c (trigonal)

Thermodynamics

Melting point 1095 °C
 α - β Phase transition 925 °C

Physical properties

Thermal exp. coeff.
 $\alpha_{11} = 4 \times 10^{-6} / ^\circ C$
 $\alpha_{33} = 36 \times 10^{-6} / ^\circ C$

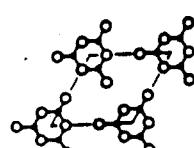
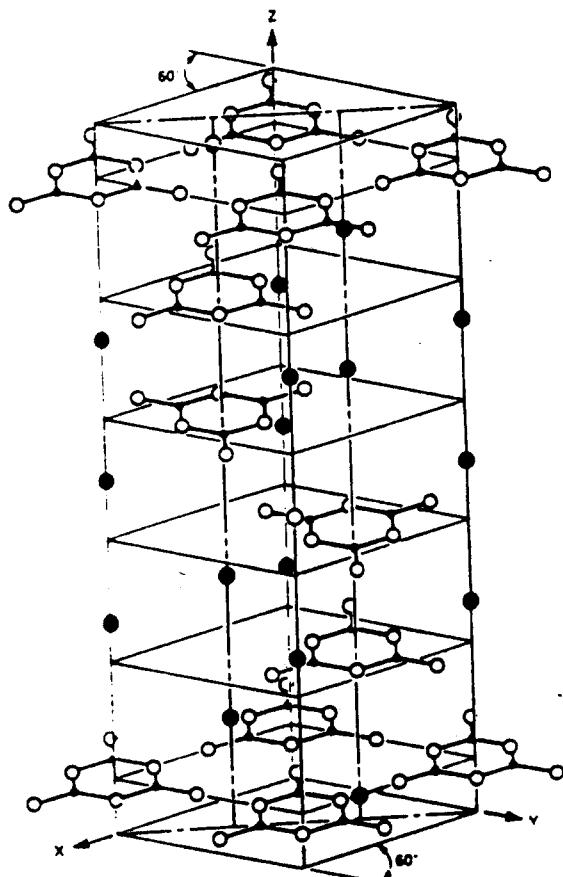
Thermal conductivities
 $K_{11} = 0.08 \text{ W/m } ^\circ K$
 $K_{33} = 0.8 \text{ W/m } ^\circ K$

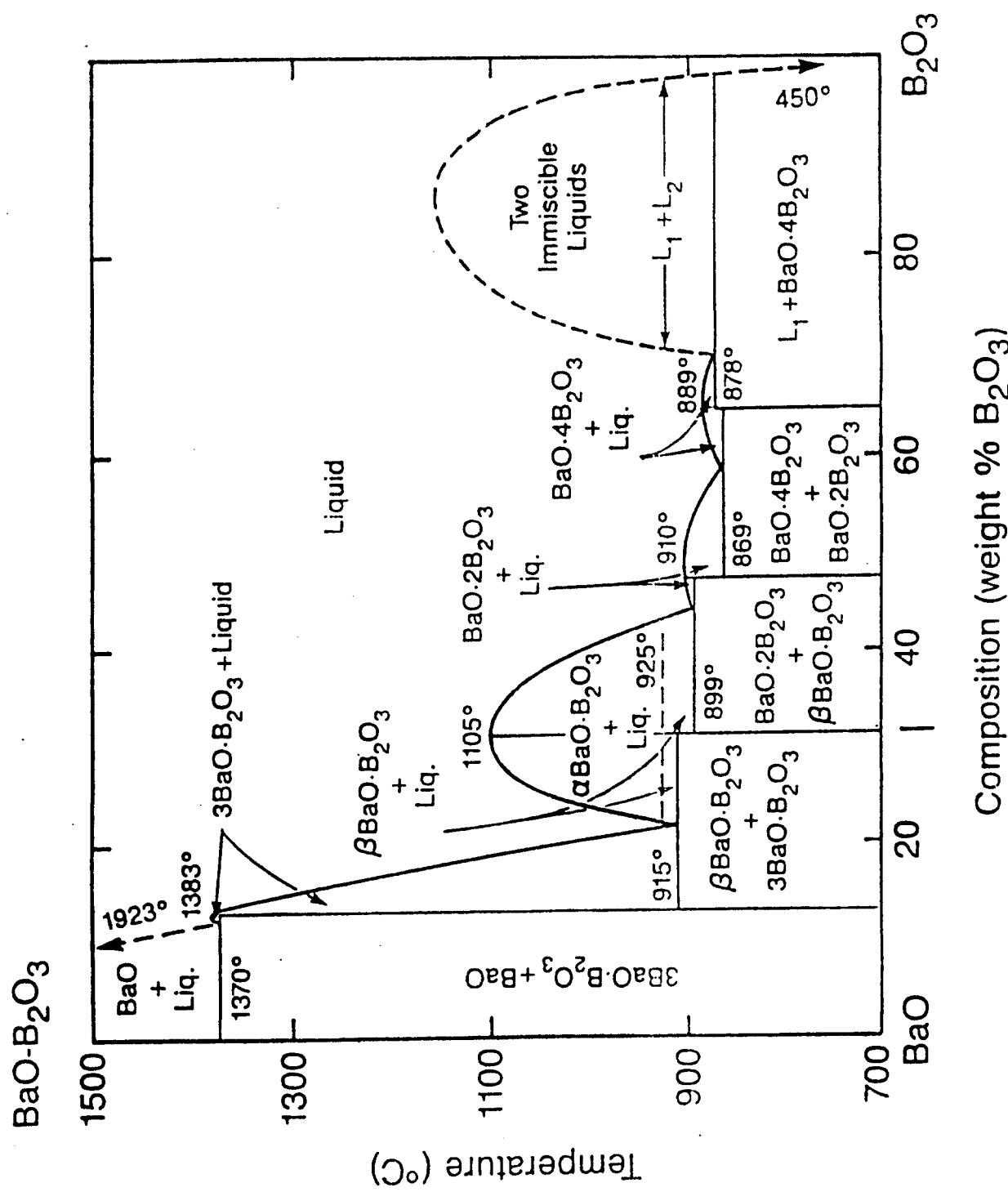
Transparency 0.190-3.50 μm

Phasematchable wavelengths (SHG)
0.205-1.50 μm

Damage threshold ($\lambda : 1.064 \mu m$)
- 13-15 GW/cm²

Unit cell





Comparison of BBO crystal growth techniques

	Solution (flux) growth	Melt growth
Advantages	<ul style="list-style-type: none">- Stable growth- Strain free- Large size obtainable	<ul style="list-style-type: none">- Faster pulling rate: 0.5-10 mm/h- Inclusion free
Disadvantages	<ul style="list-style-type: none">- Crystal pulling rate: <1mm/day- Inclusions and light scatters- Compositional contamination due to flux	<ul style="list-style-type: none">- Meta-stable growth- Strain and cracks- Restricted crystal size and growth direction

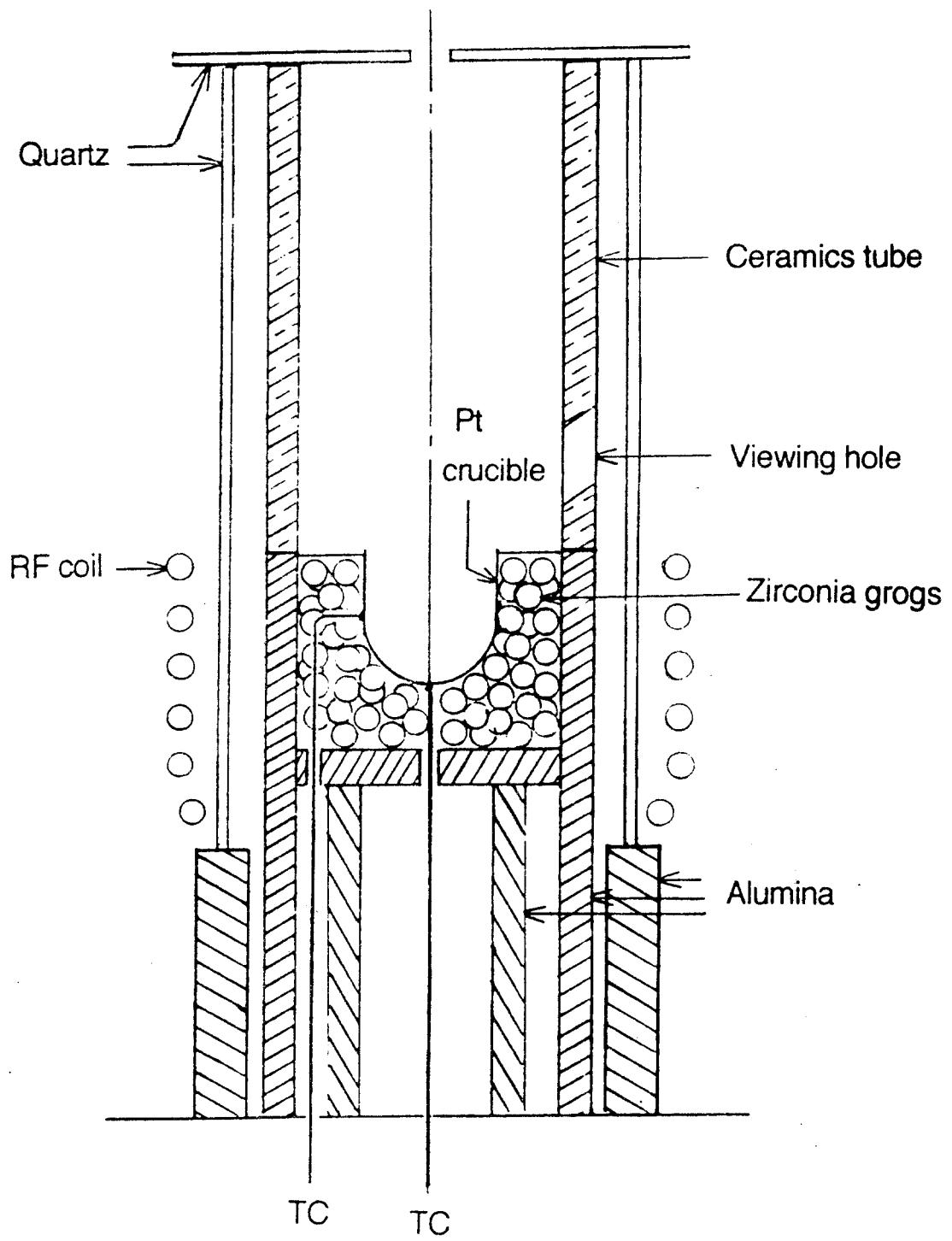
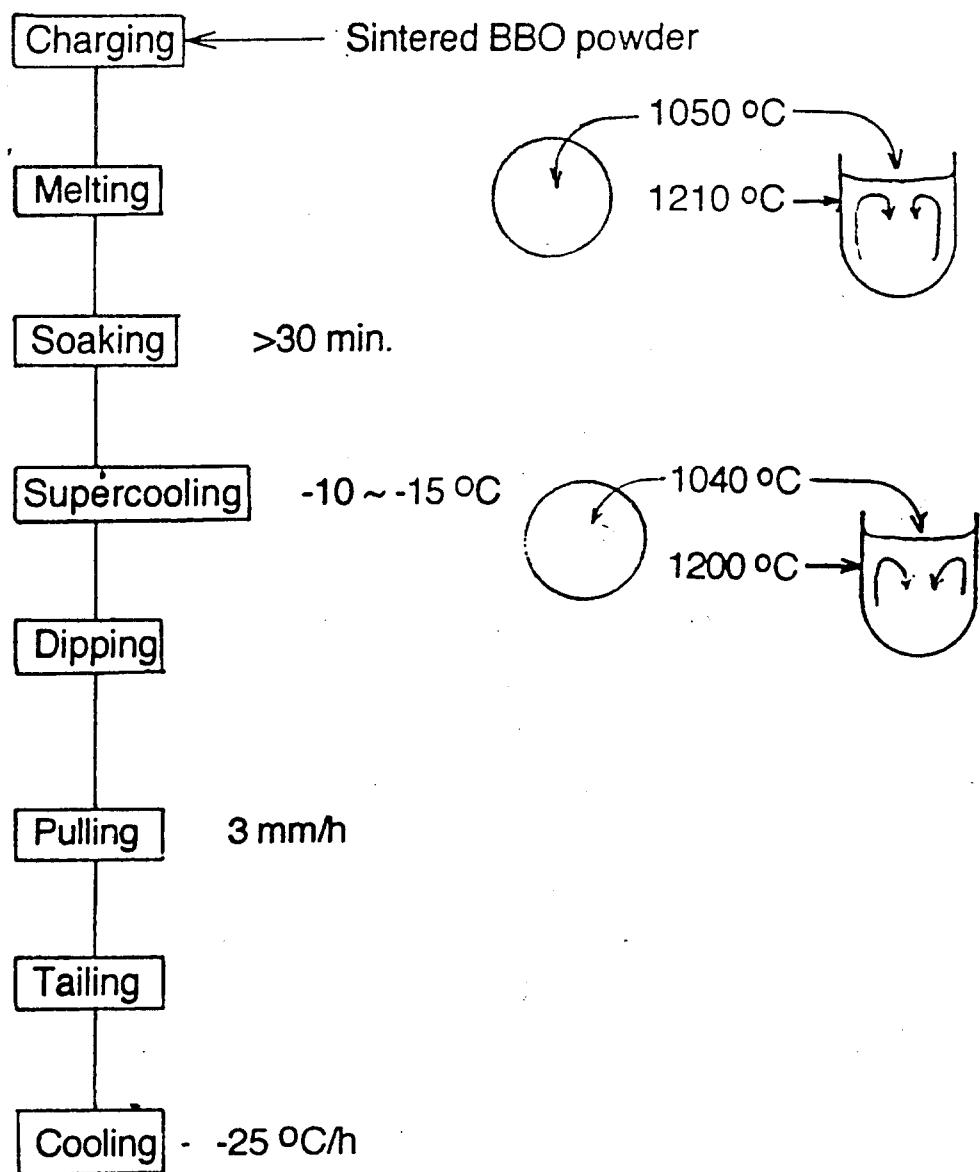


Fig. Construction of a d-CZ furnace

Flow chart of BBO crystal growth



$$\frac{\Delta T}{\Delta Z_p} = 340^\circ C/mm$$

$$\frac{\Delta T}{\Delta Z_d} = 250^\circ C/mm$$

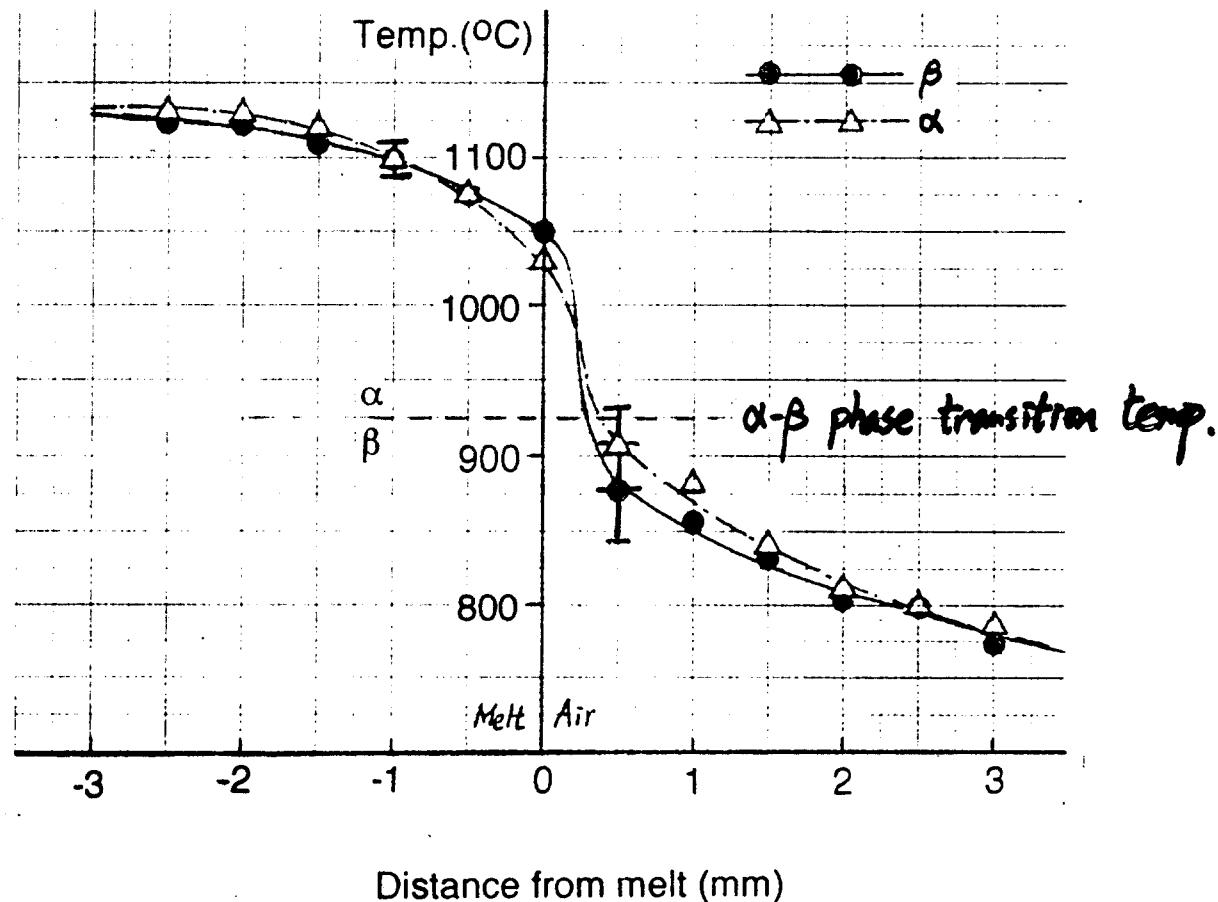


Fig. Temp. gradient near the growing point

Seeds

- (1). Pt 3-wire bundle -----> mostly α -phase
- (2). β -BBO crystal -----> β -phase > α -
- size : ϕ 2~3 mm, 5~10 mm in length

Surface cracks -----> Crystal is apt to drop
into melt on pulling

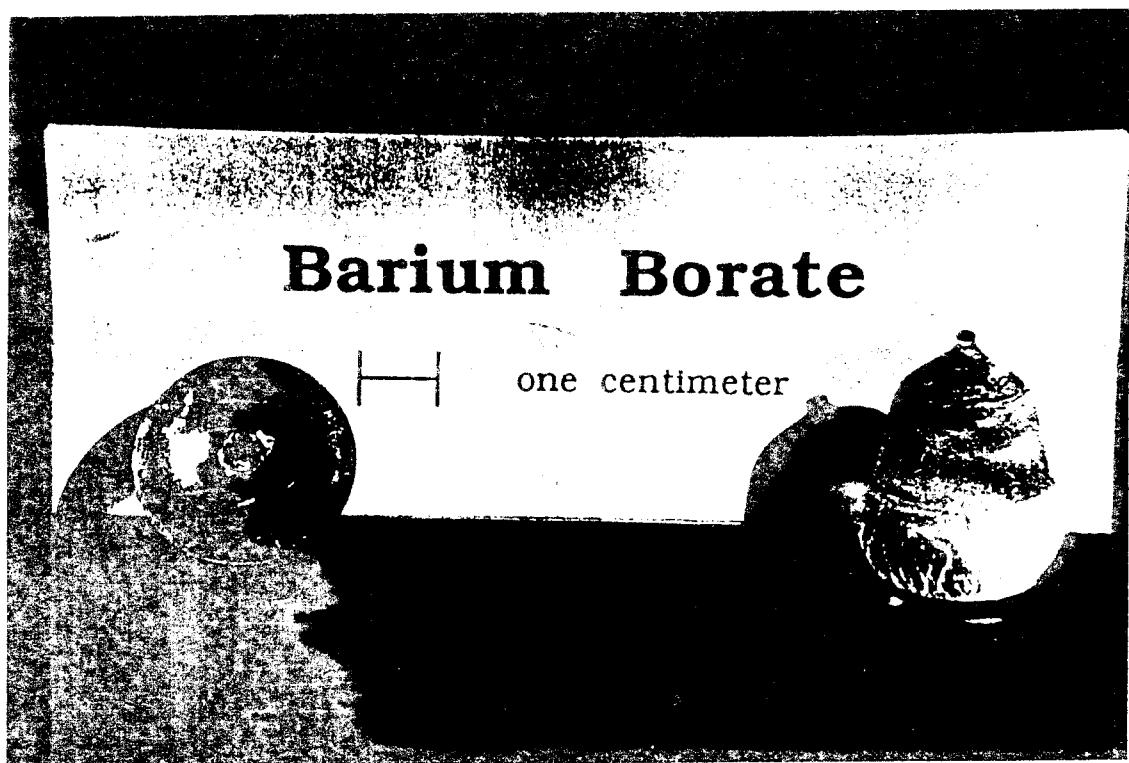
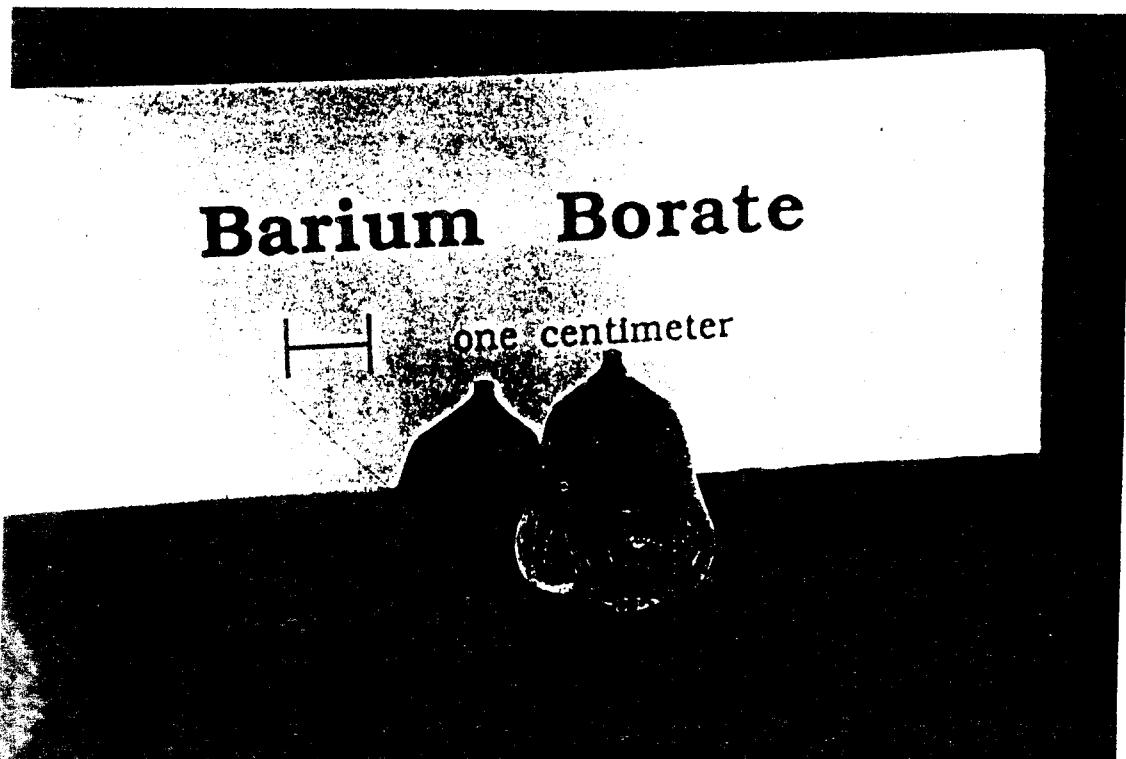


Fig. β -BBO single crystals

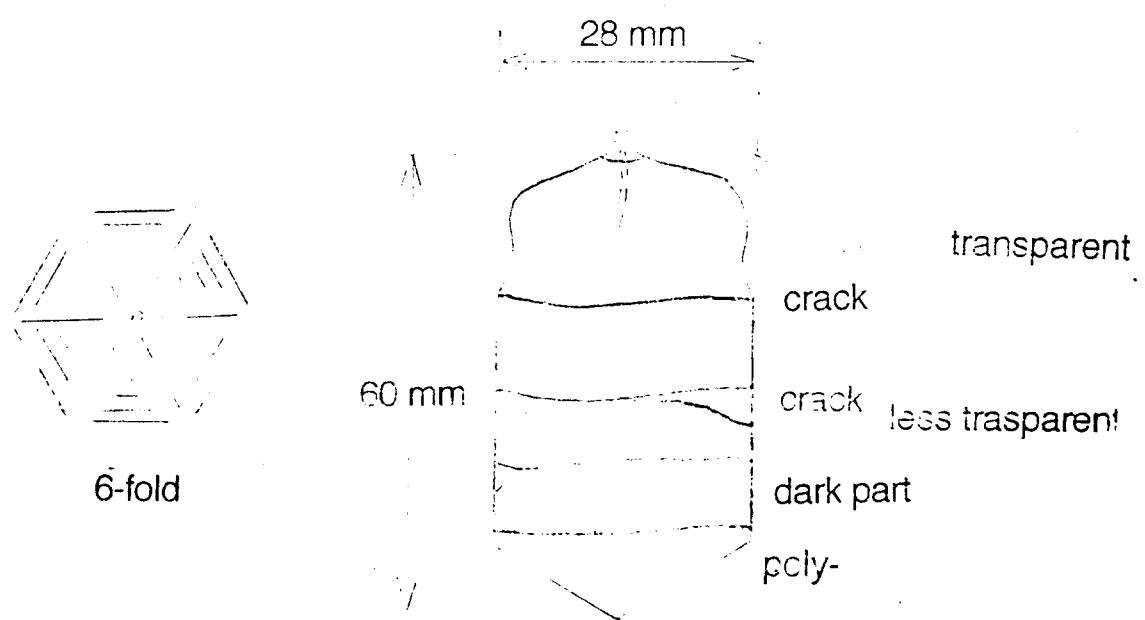
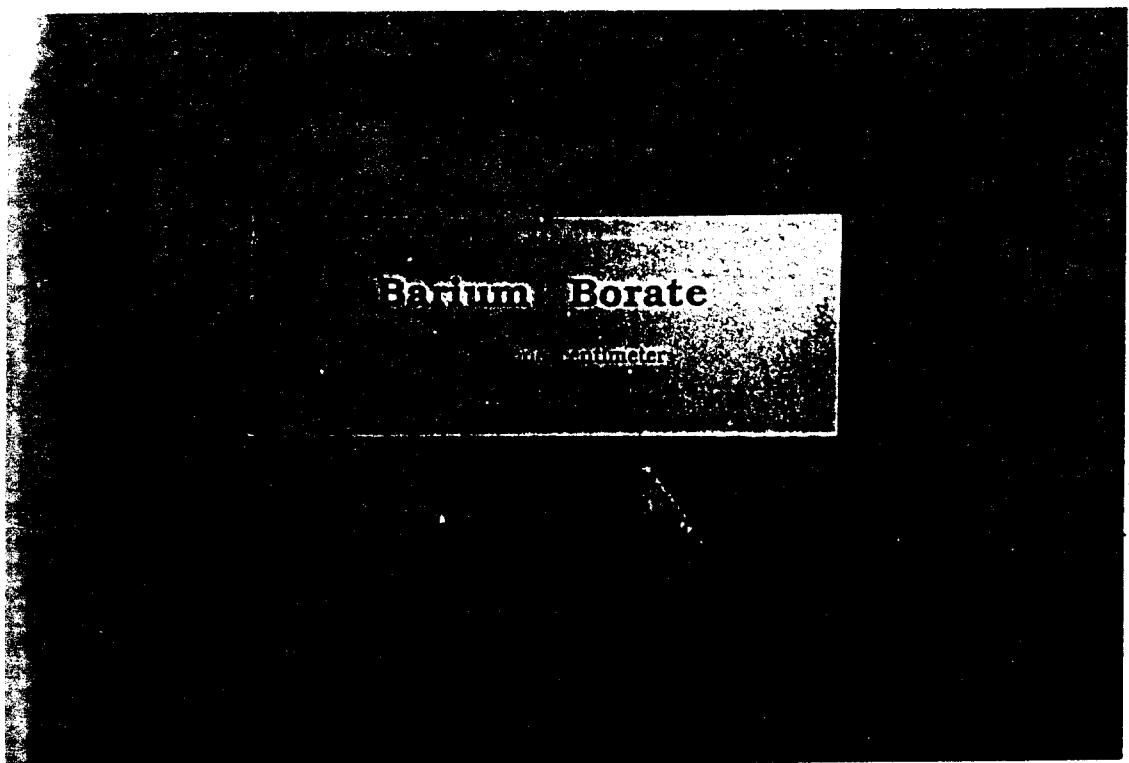


Fig. β -BBO crystal grown from the much used melt

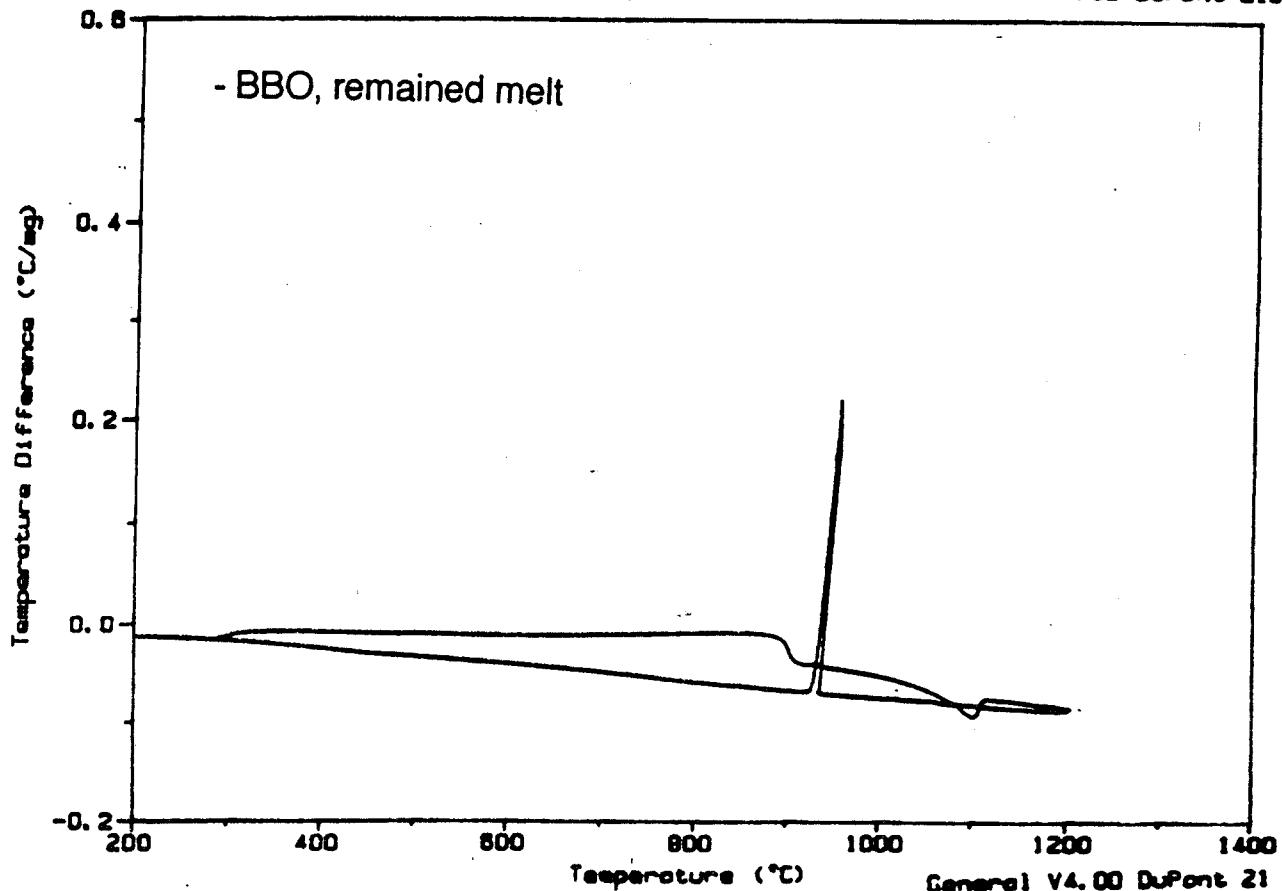
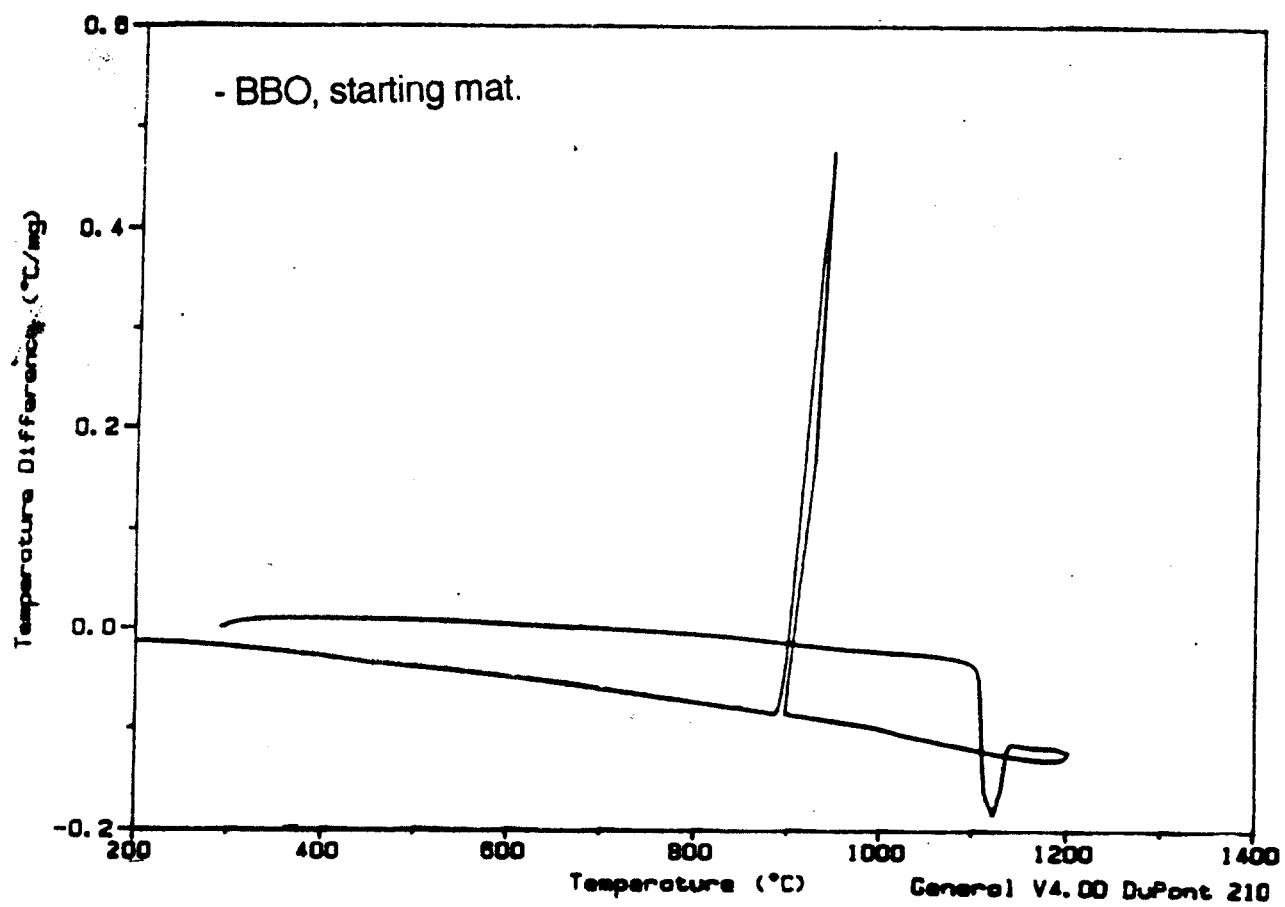
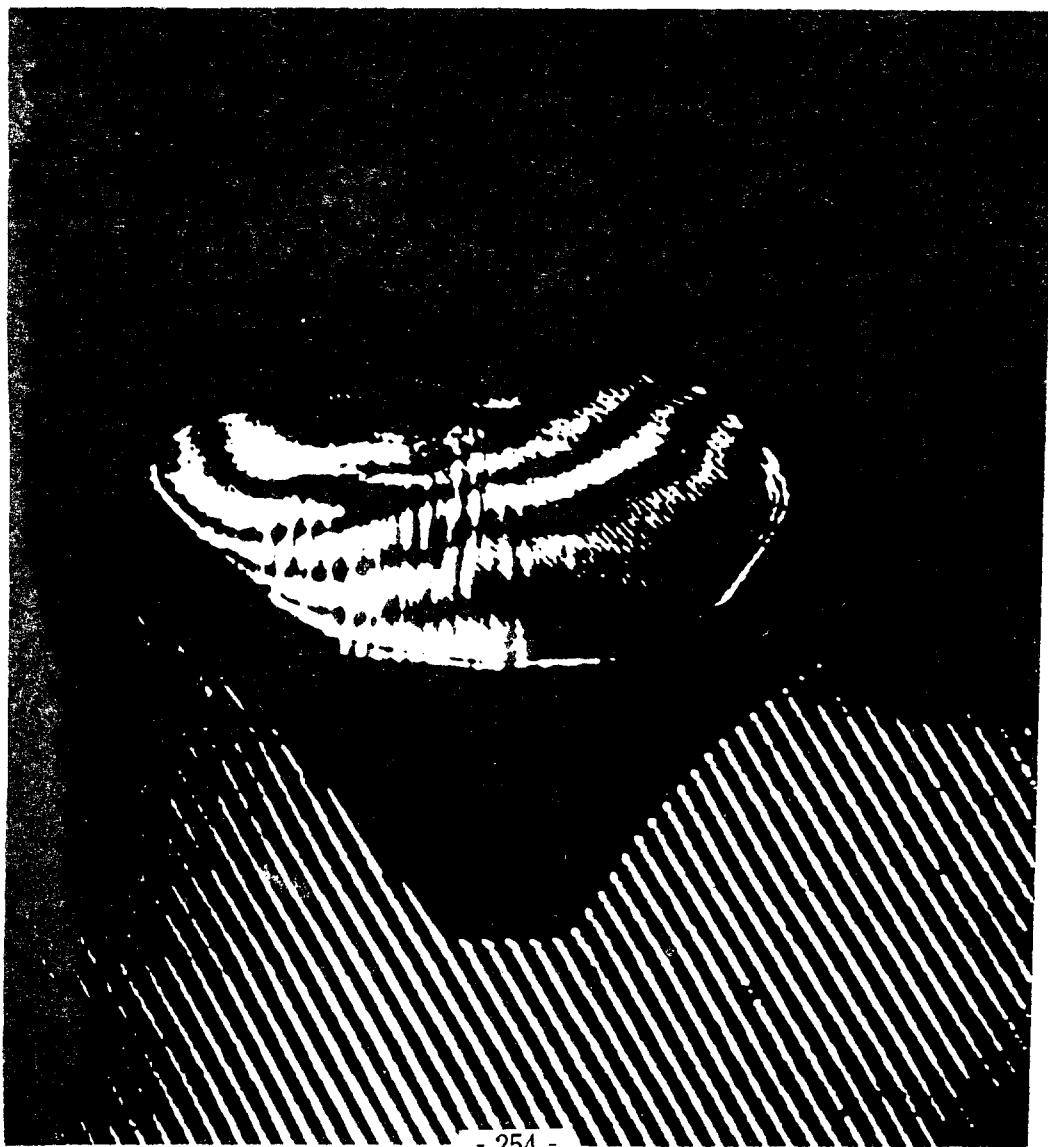
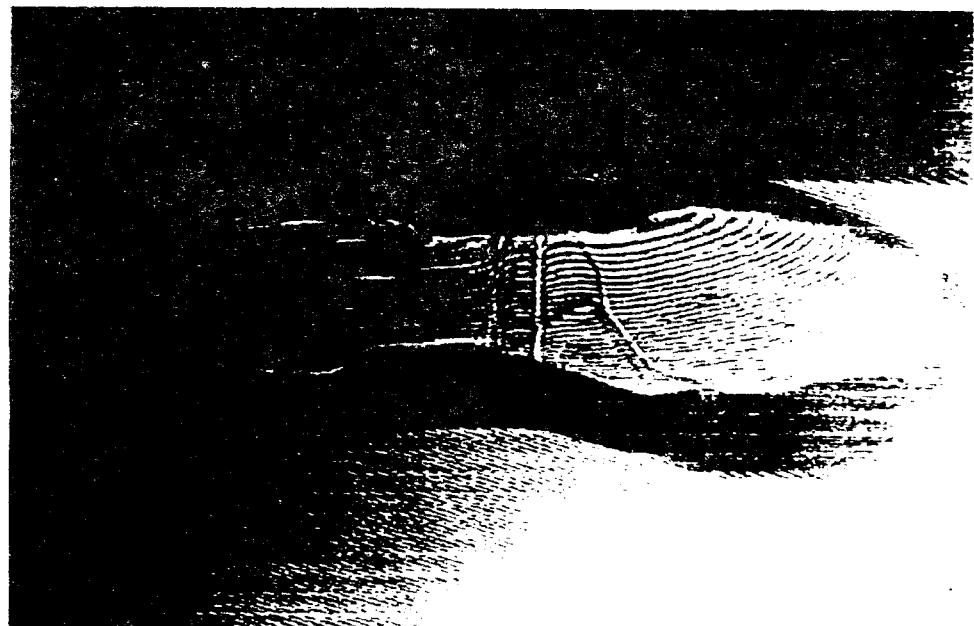
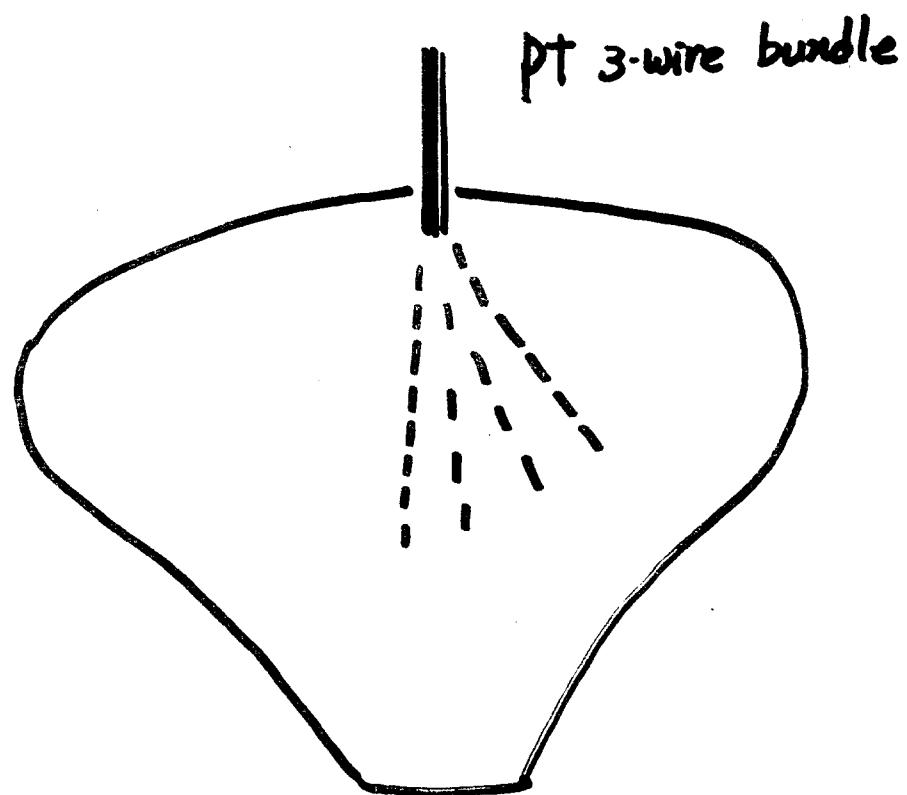
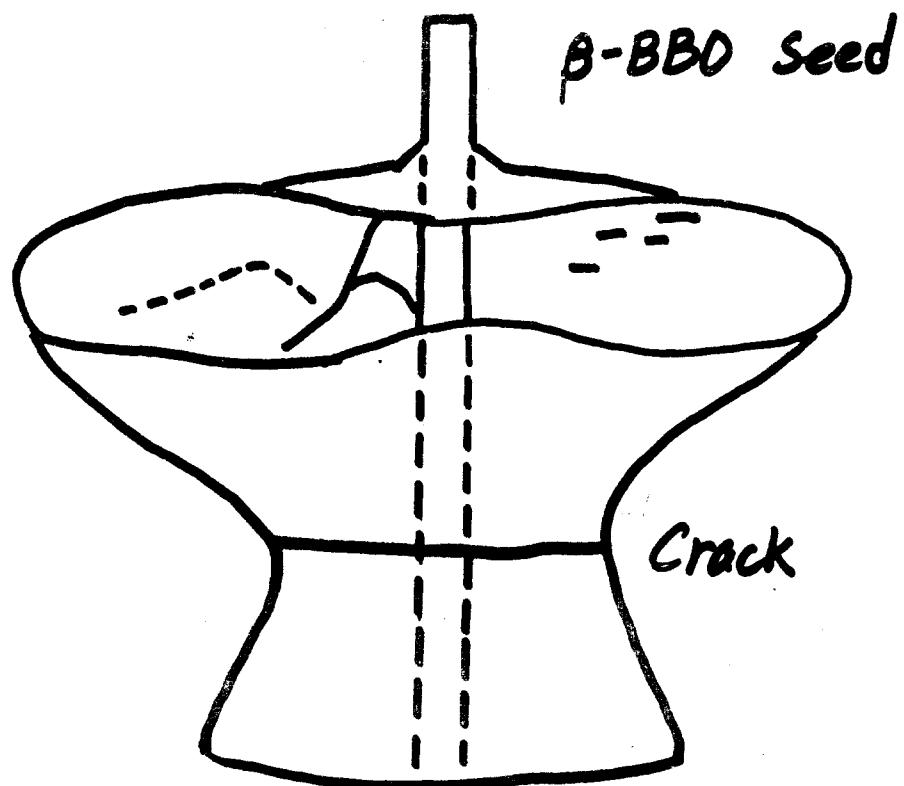
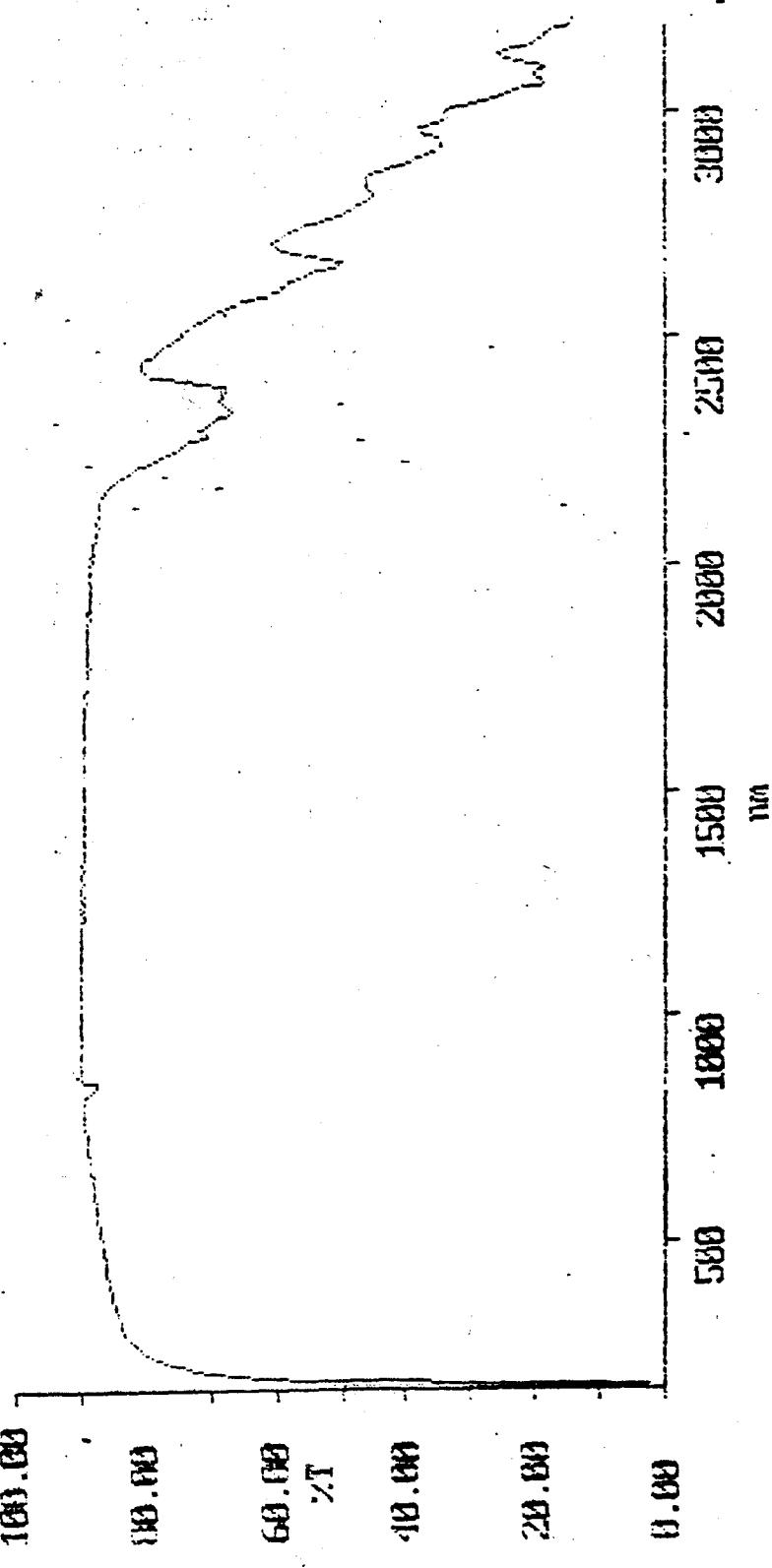


Fig. DTA curves of the starting sintered mat. and the remained melt of BBO





X: 0003145; 3260.0 - 170.0 nm; pts 3031; int 1.00; ord 1.7130 - 90.5385 zt
Int: 15.30:24 95.07/H



Conclusions

- β -BBO single crystals, $\phi 2\text{cm}$, $2\sim 4\text{cm}$ in length
- Large dT/dz on melt ----> β -BBO crystals
- Seed, β -BBO crystal
- Higher quality than flux grown BBO crystals

Future works

- Defects investigation
- Large size β -BBO single crystal growth
- Doped BBO crystal growth